

Supporting Information

External field control and characteristic quantities of Rashba spin orbit coupling in MA_2Z_4 derived monolayer materials

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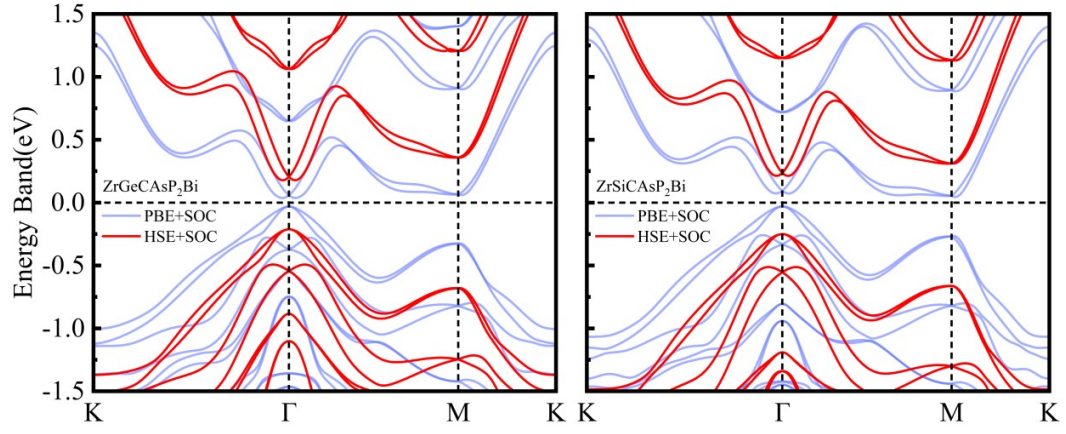


Figure S1. Band structures of several materials in MA_2Z_4 under PBE+SOC and HSE+SOC.

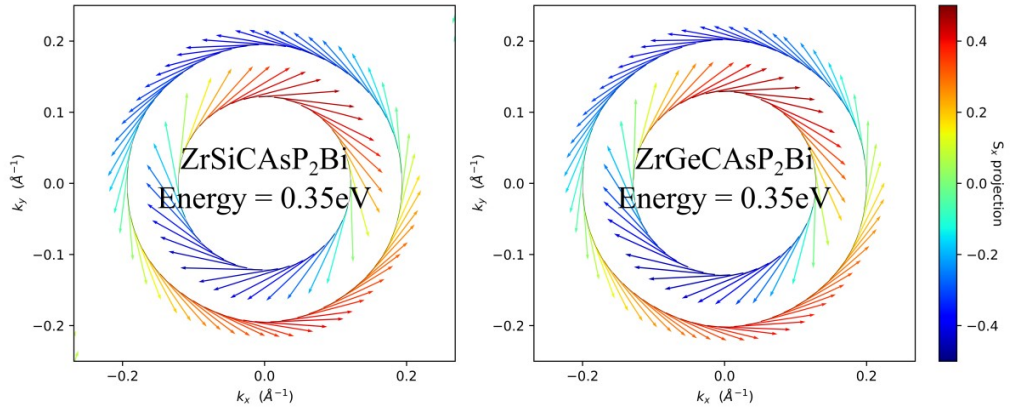
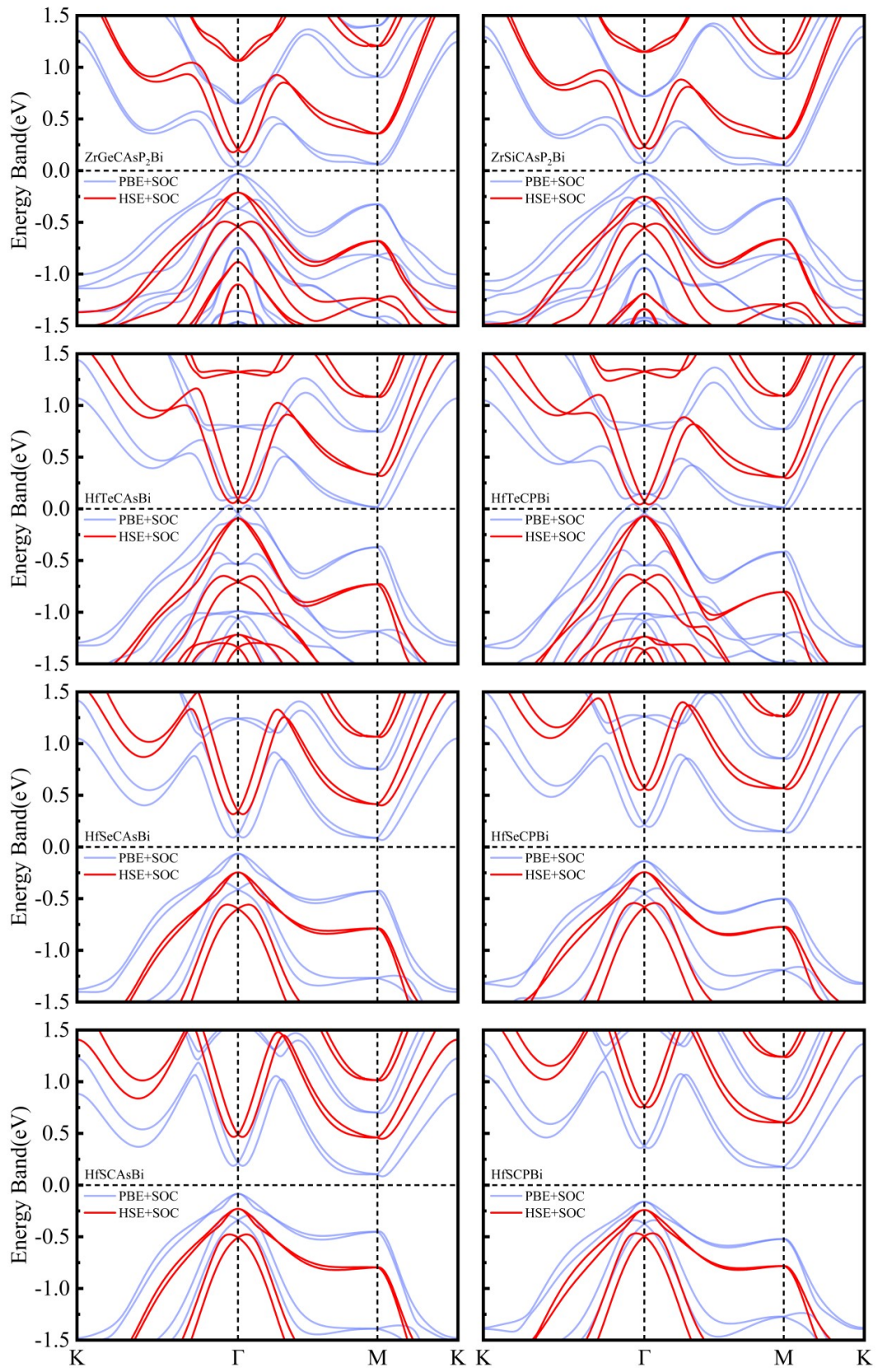
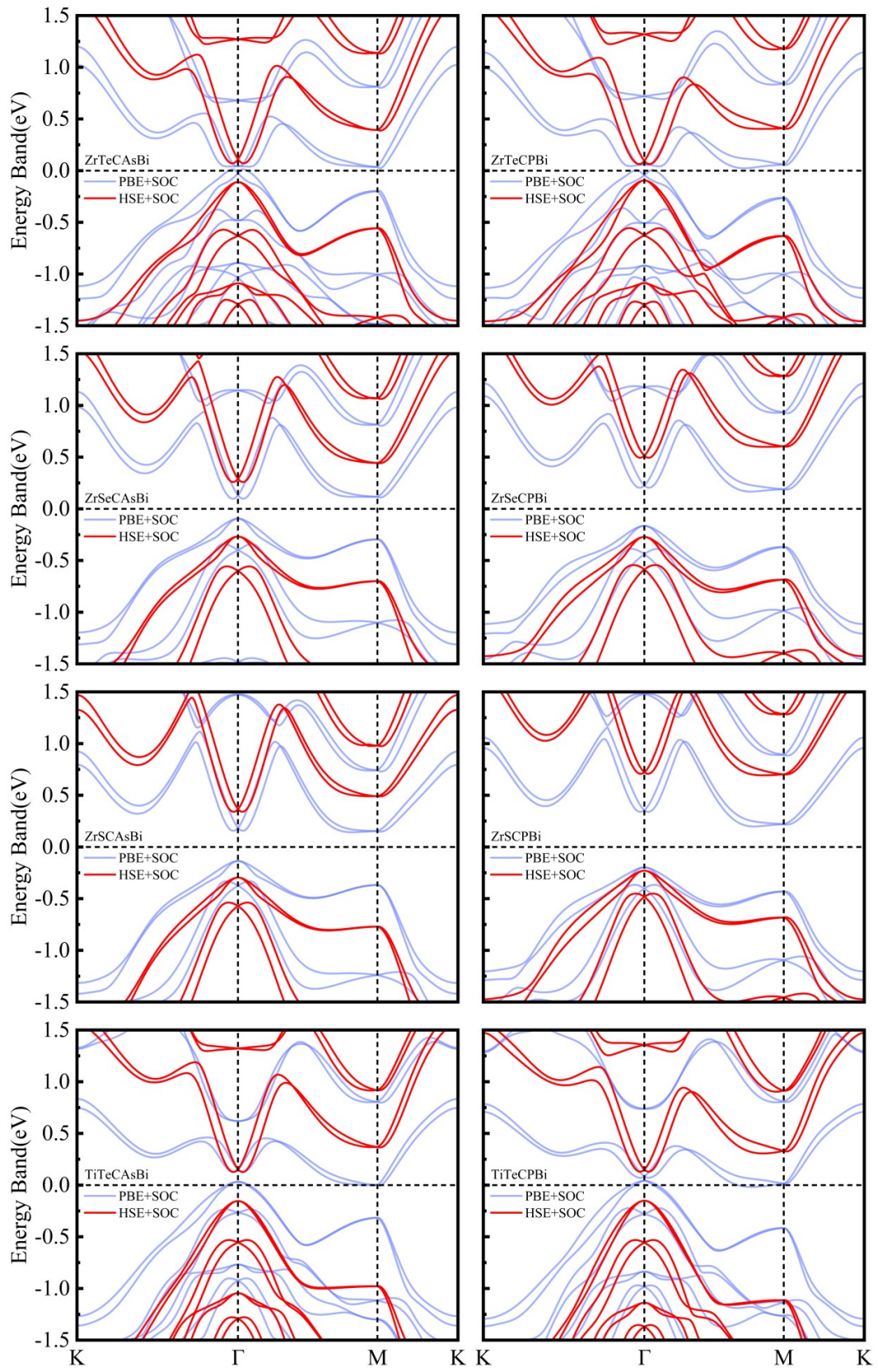


Figure S2. Spin texture diagrams of several materials in MA_2Z_4 at their respective energies (referenced to the Fermi level).





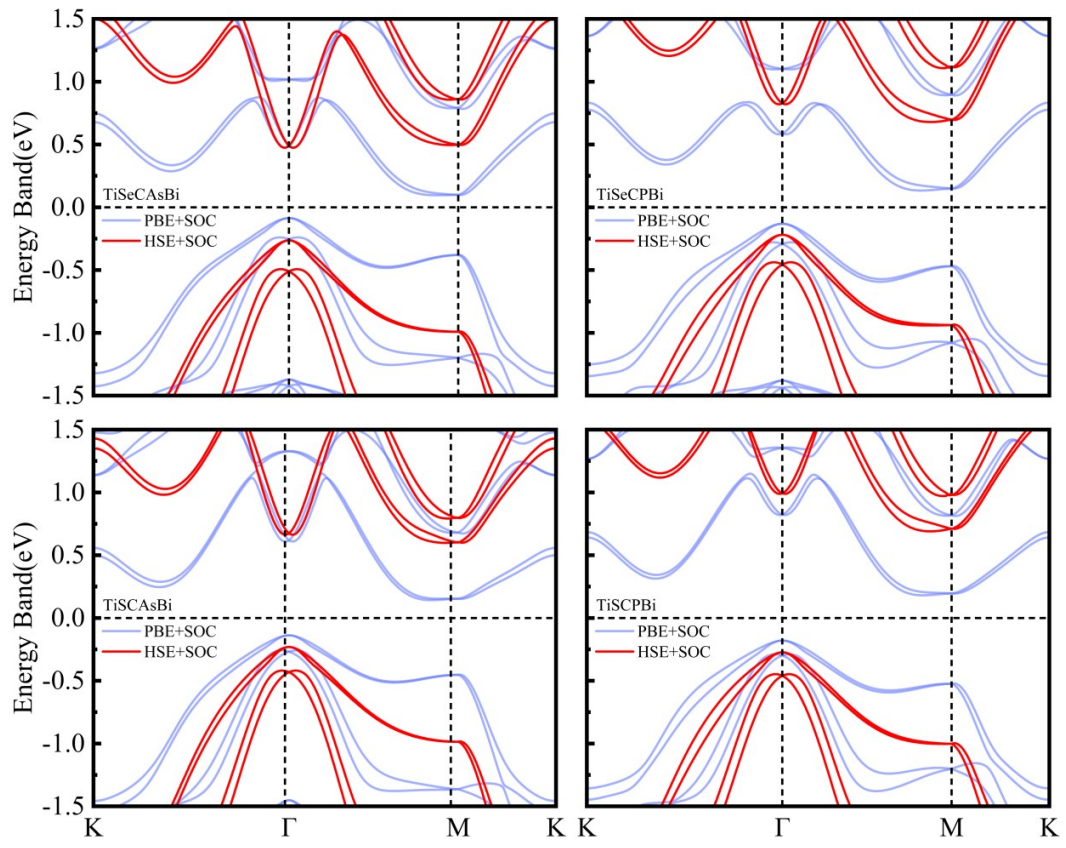
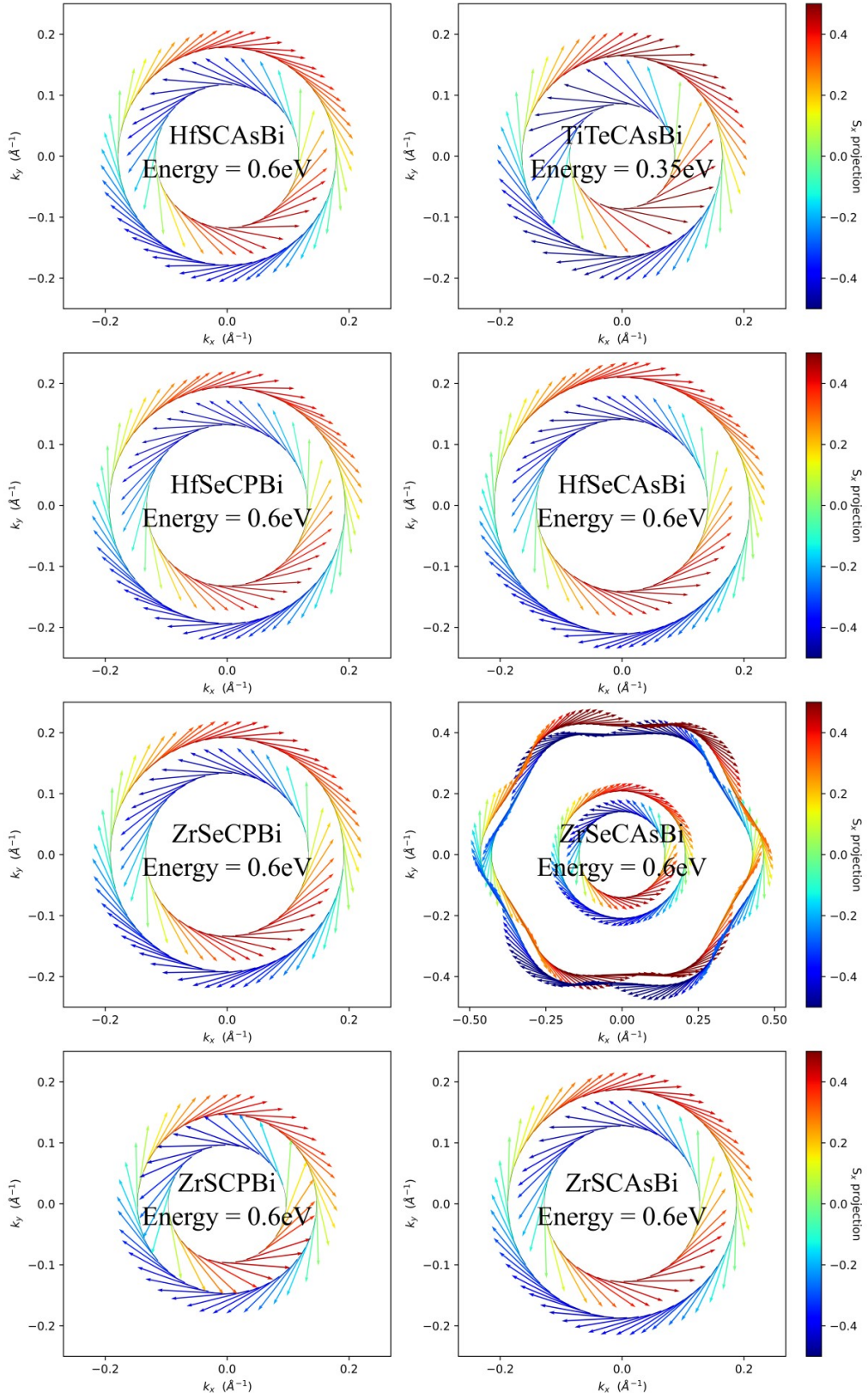


Figure S3. Band structures of several materials in MXAZ_2 under PBE+SOC and HSE+SOC.



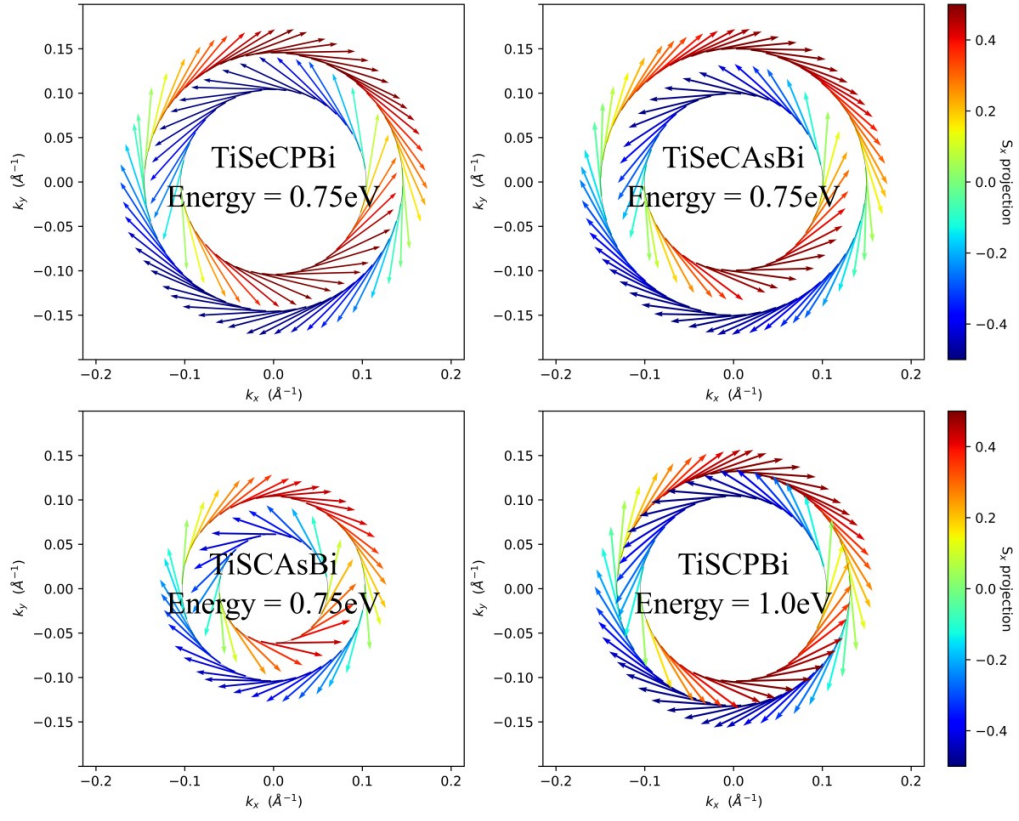
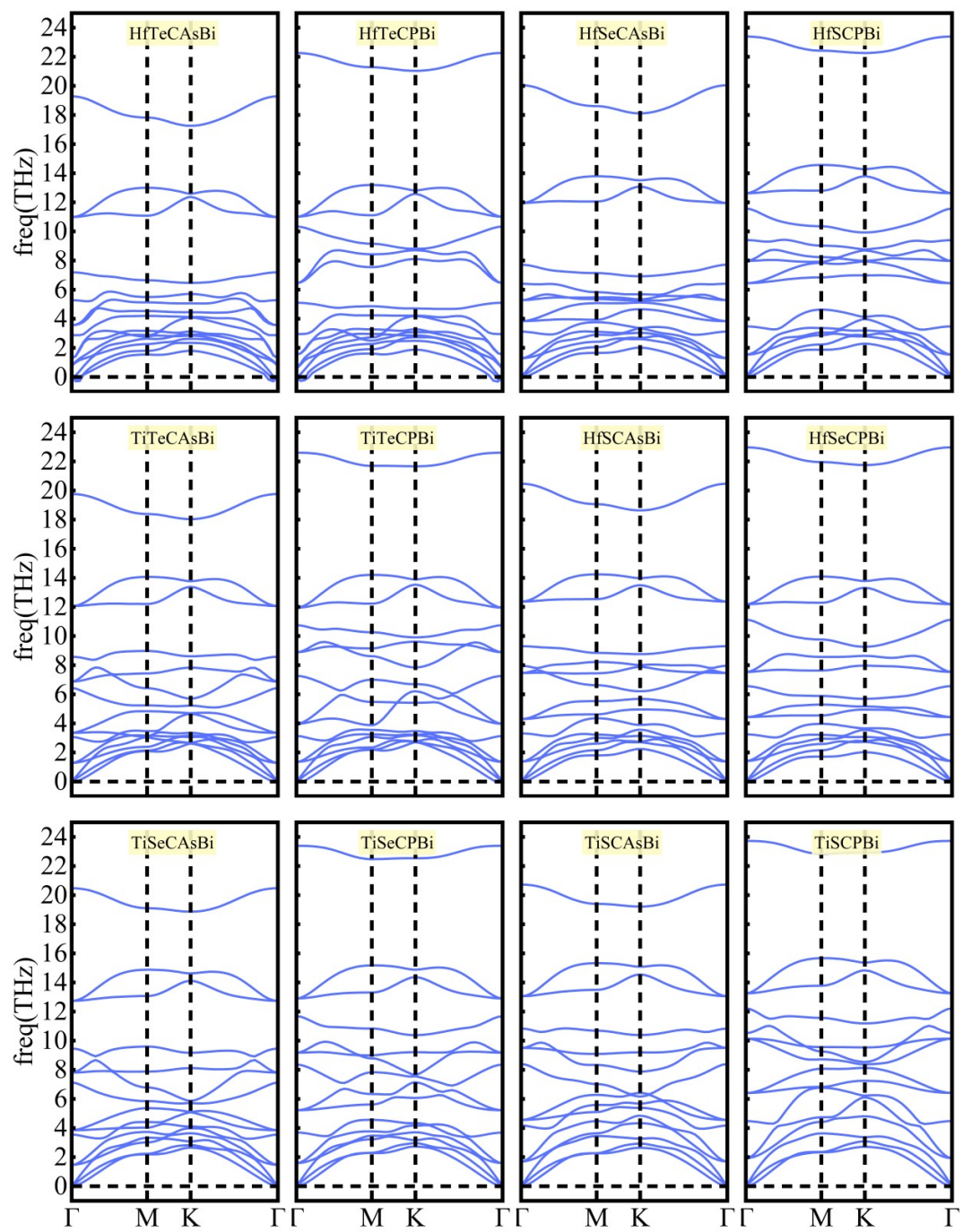


Figure S4. Spin texture diagrams of several materials in MXAZ_2 at their respective energies (referenced to the Fermi level).



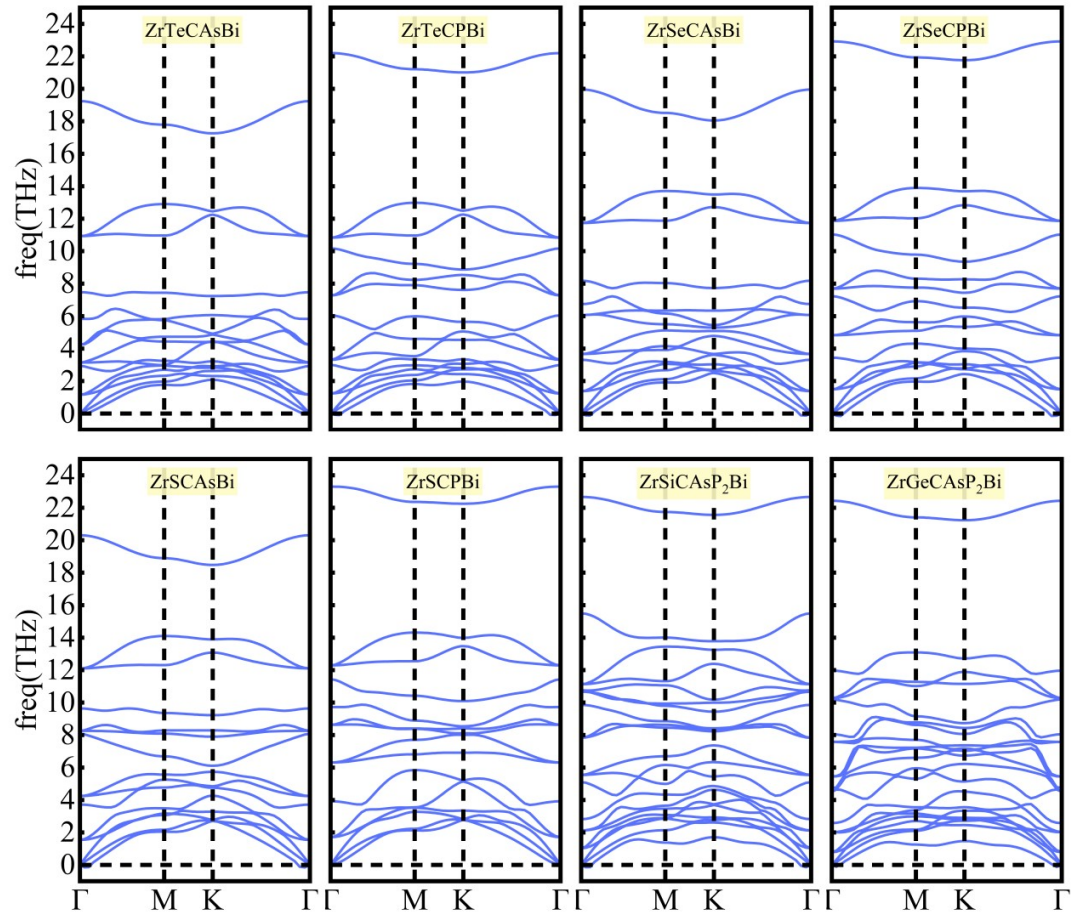
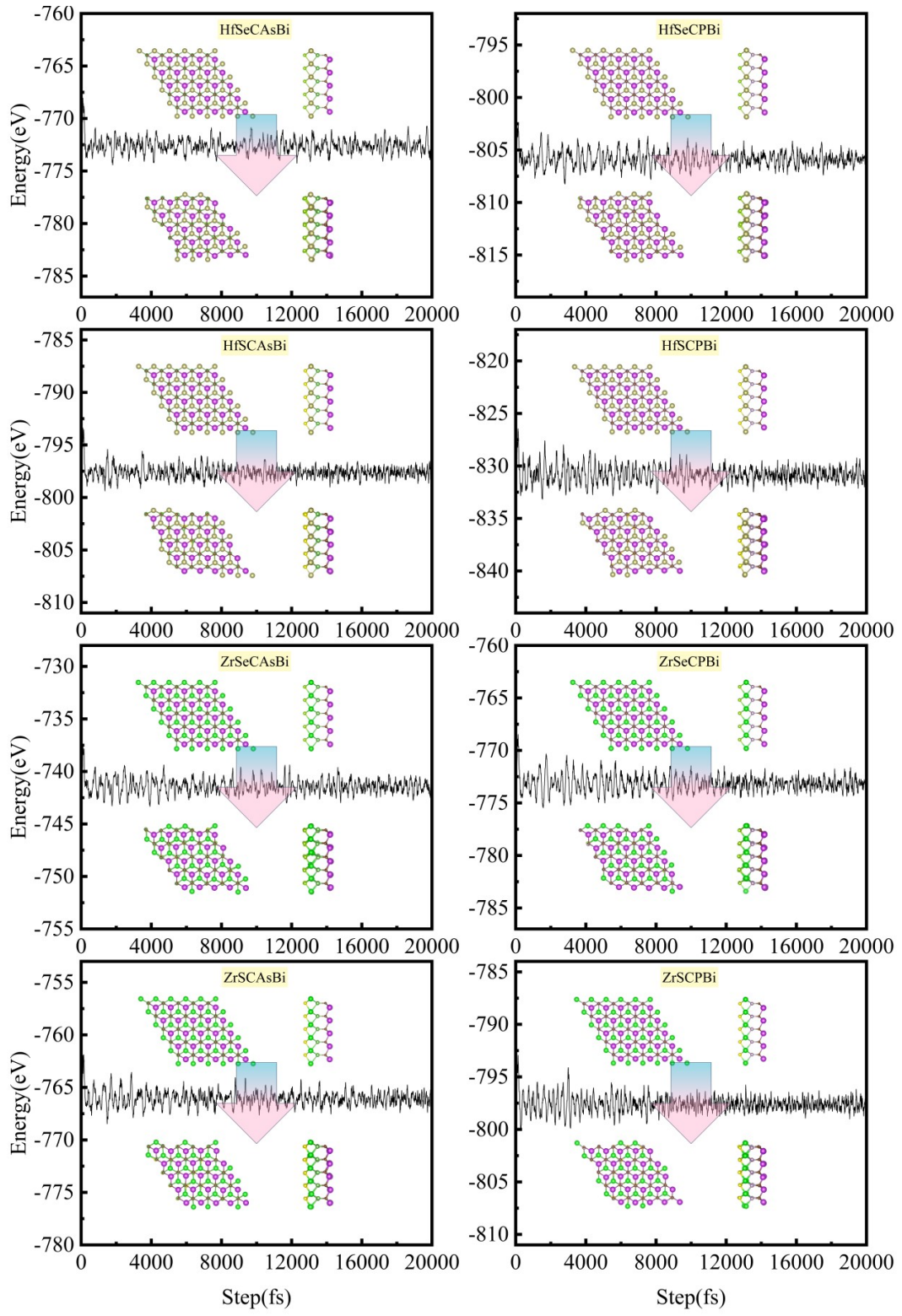


Figure S5. Phonon spectra of several materials in MA₂Z₄ and MXAZ₂.



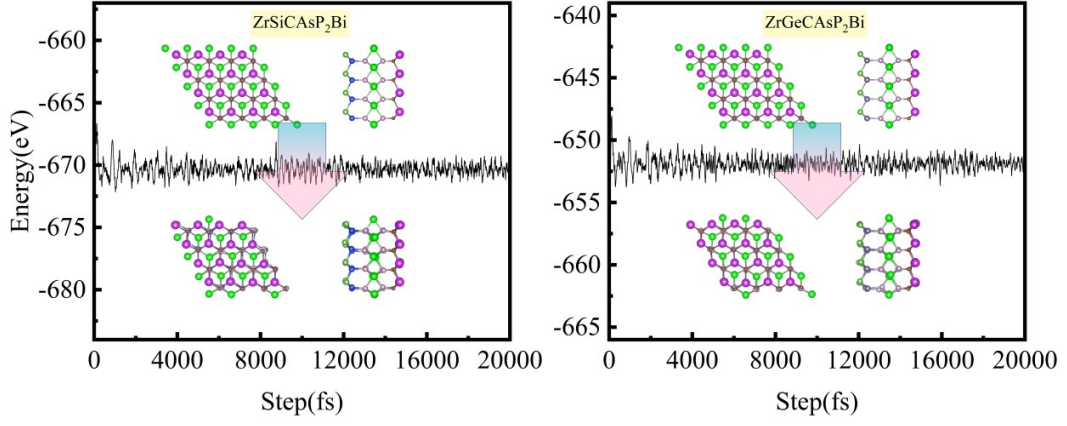


Figure S6. Molecular dynamics simulations of several materials in MA_2Z_4 and $MXAZ_2$ at 400K.

TABLE S1. The Rashba strength α_R of various materials, the difference in work function between the two sides of the material $\Delta\Phi$, the dipole moment μ within the material, Z represents the sum of atomic numbers, and the electronegativity χ of atoms at different positions.

Material	$\alpha_R(\text{eV}\text{\AA})$	$\Delta\Phi(\text{V})$	$\mu(\text{e}\text{\AA})$	Z	$\chi_M(\text{kJ/mol})$	$\chi_X(\text{kJ/mol})$	$\chi_{Z1}(\text{kJ/mol})$
HfTeCAsBi	2.083	1.061	-0.0739	246	1.30	2.10	2.18
HfTeCPBi	1.775	1.268	-0.0865	228	1.30	2.10	2.19
HfSeCAsBi	1.847	1.275	-0.0851	228	1.30	2.55	2.18
HfSeCPBi	1.380	1.487	-0.0973	210	1.30	2.55	2.19
HfSCAsBi	1.631	1.419	-0.0931	210	1.30	2.58	2.18
HfSCPBi	1.144	1.602	-0.1023	192	1.30	2.58	2.19
ZrTeCAsBi	2.072	1.118	-0.0783	214	1.33	2.10	2.18
ZrTeCPBi	1.749	1.322	-0.0908	196	1.33	2.10	2.19
ZrSeCAsBi	1.849	1.348	-0.0912	196	1.33	2.55	2.18
ZrSeCPBi	1.346	1.494	-0.0988	178	1.33	2.55	2.19
ZrSCAsBi	1.668	1.429	-0.0942	178	1.33	2.58	2.18
ZrSCPBi	1.133	1.609	-0.1040	160	1.33	2.58	2.19
TiTeCAsBi	1.667	1.19	-0.0780	196	1.54	2.10	2.18
TiTeCPBi	1.360	1.341	-0.0860	178	1.54	2.10	2.19
TiSeCAsBi	1.253	1.384	-0.0869	178	1.54	2.55	2.18
TiSeCPBi	0.781	1.591	-0.0983	160	1.54	2.55	2.19
TiSCAsBi	1.030	1.623	-0.0994	160	1.54	2.58	2.18
TiSCPBi	0.552	1.788	-0.1073	142	1.54	2.58	2.19

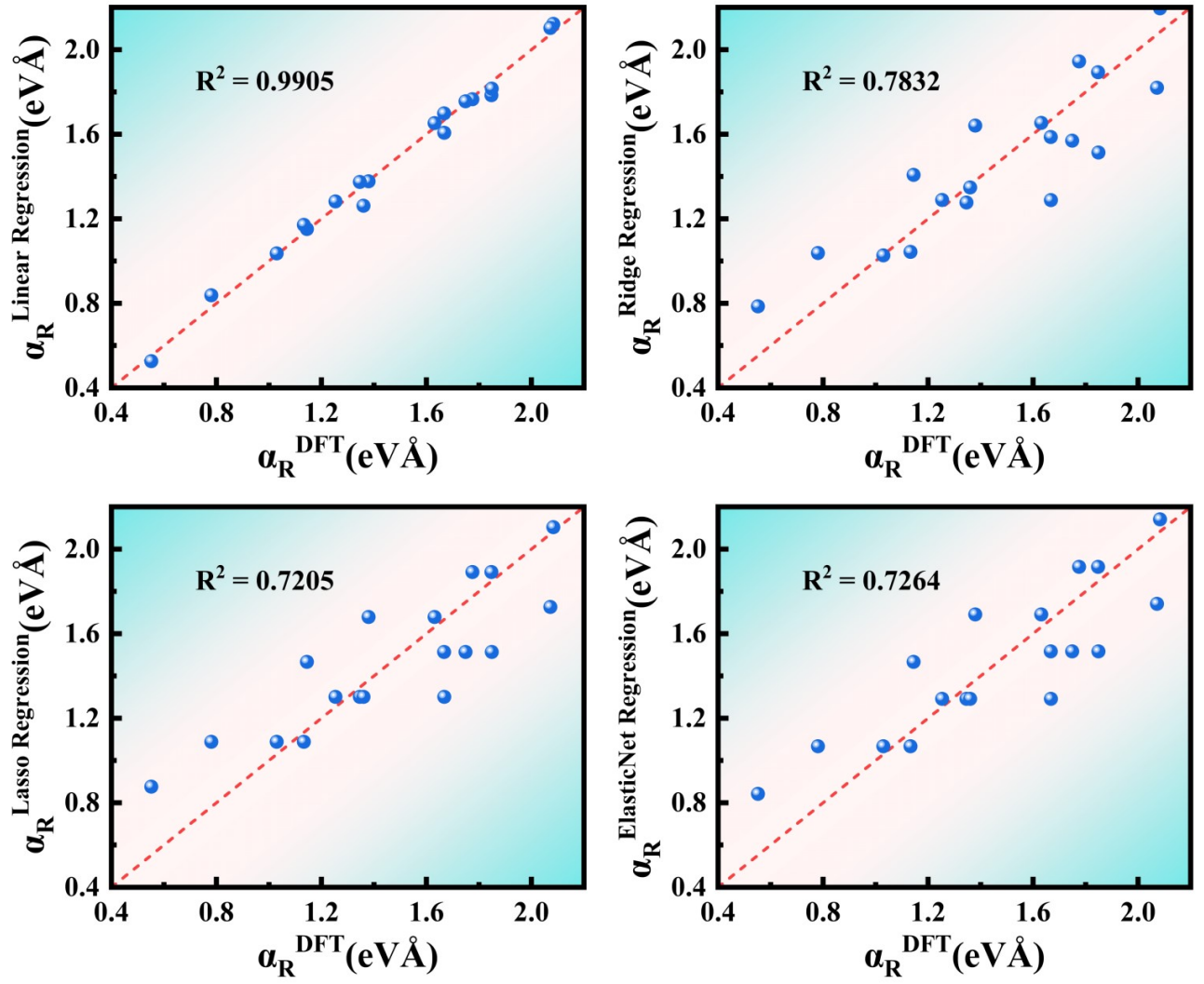


Figure S7. The comparison between the calculated values of Rashba spin-orbit coupling strength α_R obtained from different models and the results calculated by DFT method.

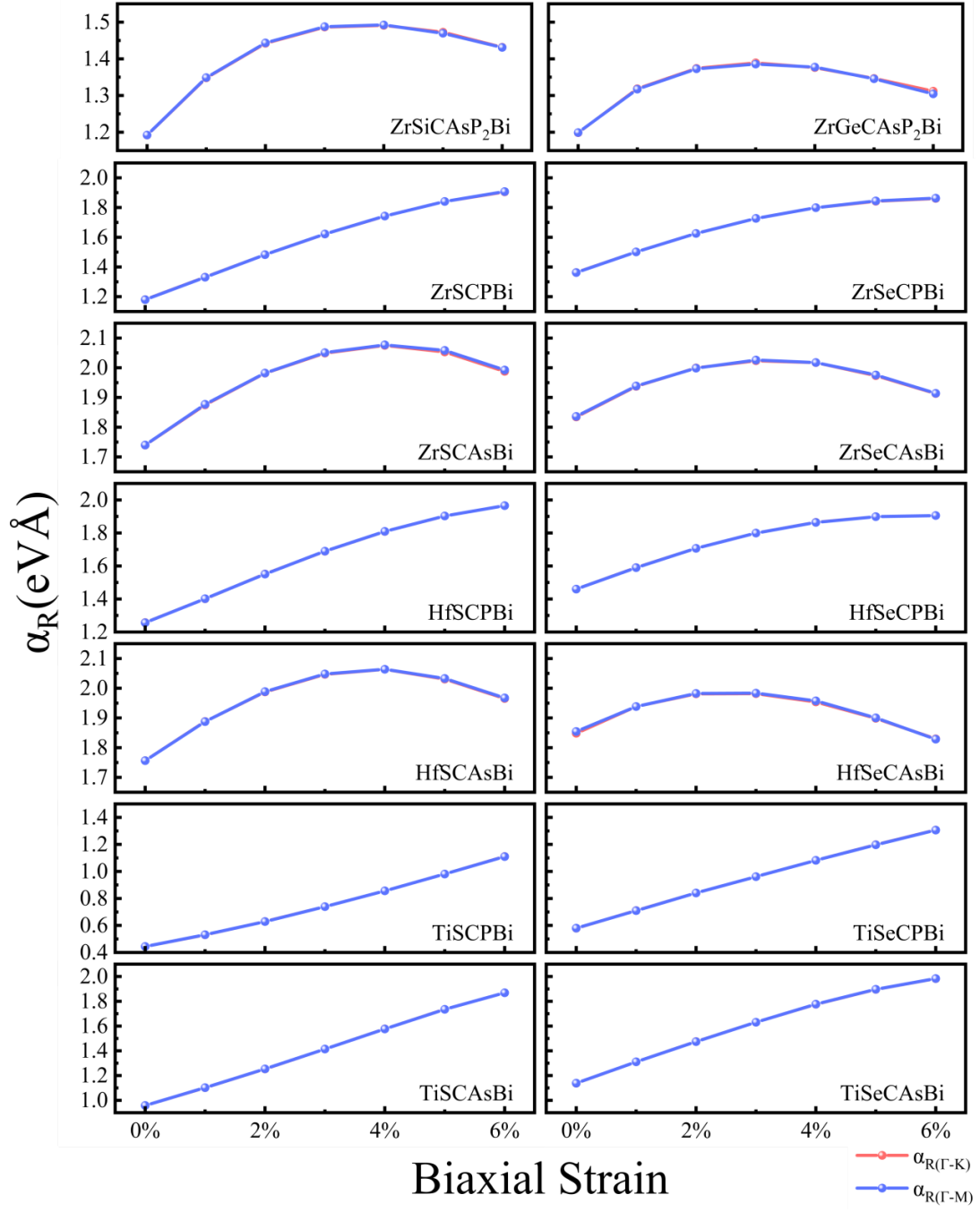


Figure S8. The variation of Rashba constant α_R with biaxial strain for several materials in MA_2Z_4 and MXAZ_2 systems.

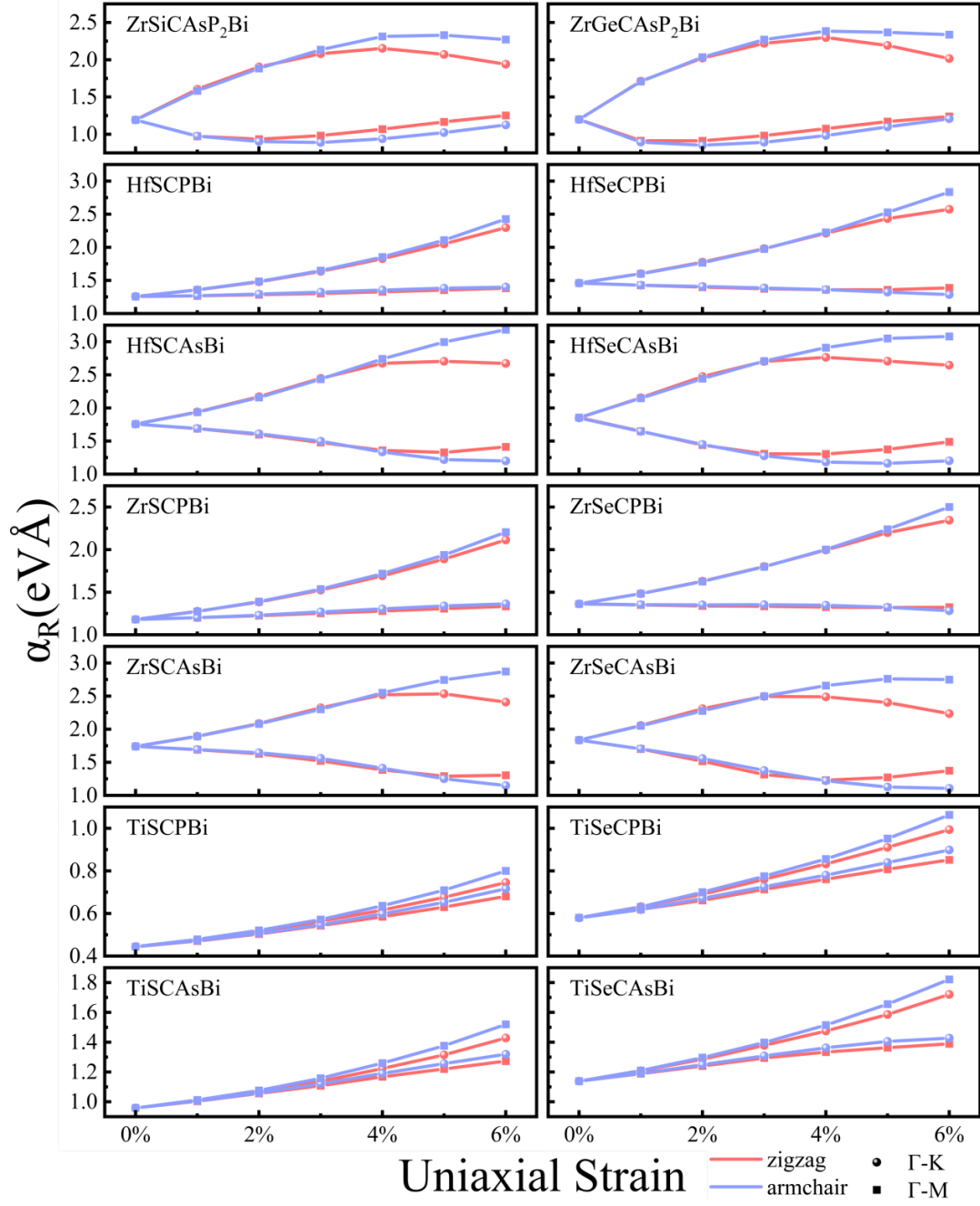


Figure S9. The variation of Rashba constant α_R with uniaxial strain for several materials in MA_2Z_4 and MXAZ_2 systems.

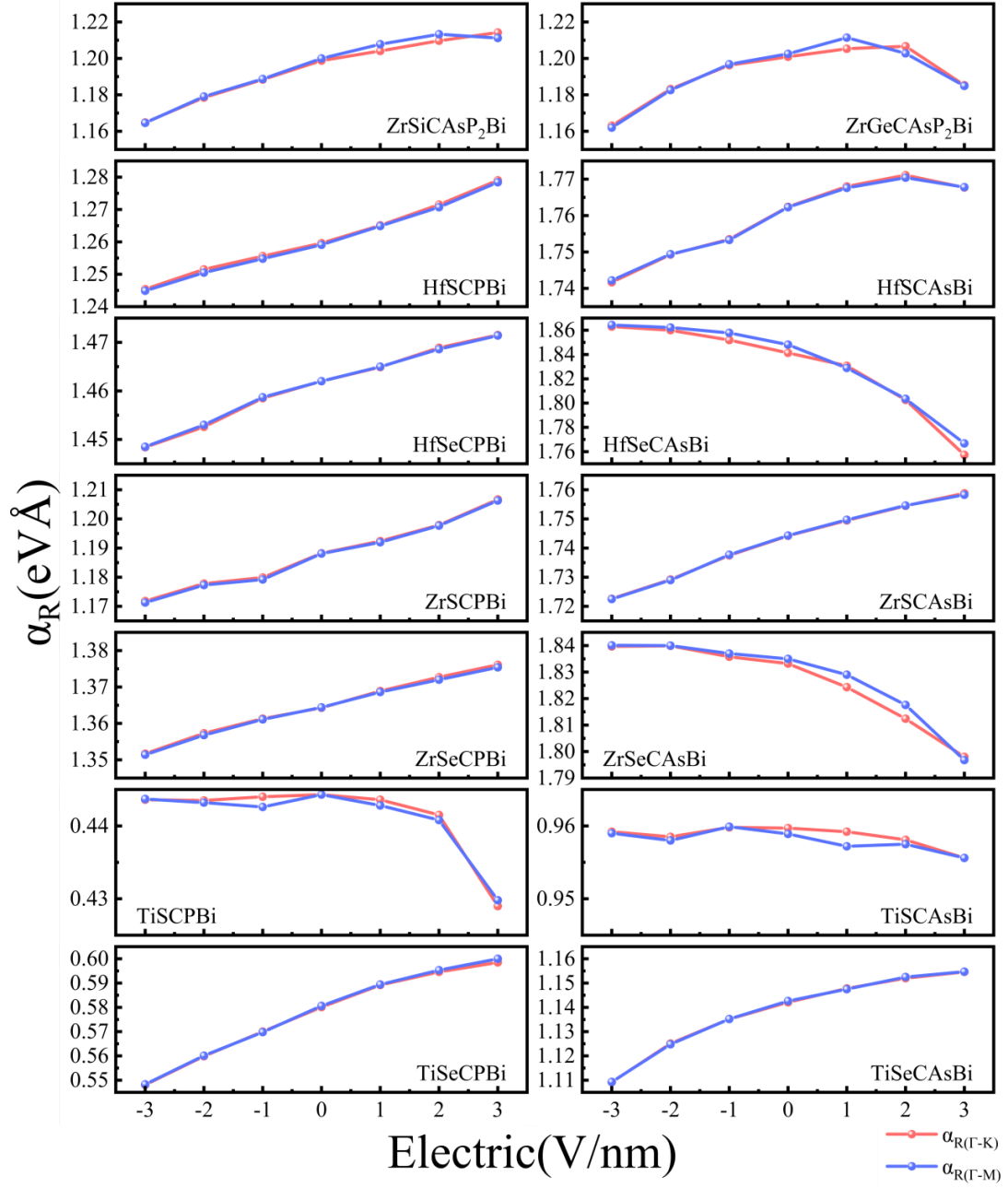


Figure S10. The variation of Rashba constant α_R with electric field for several materials in MA2Z4 and MXAZ₂ systems.

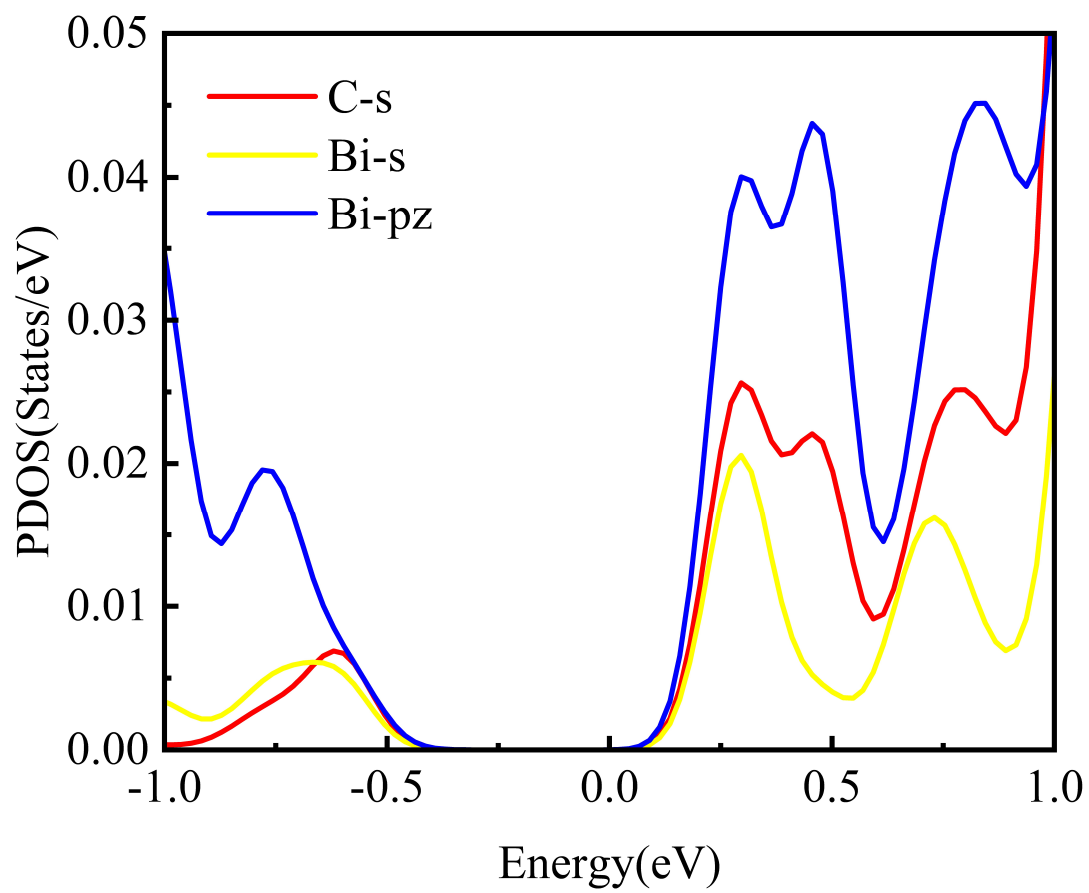


Figure S11. PDOS of the constituent atoms within the ZrSeCAsBi system.